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Modelling and characterization of a travelling-wave electro-optic modulator on InP

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Abstract. A fast travelling-wave Mach-Zehnder modulator is modelled and designed using a rigorous vectorial analysis. In order to investigate propagation characteristics, velocity and microwave loss, the semiconductor layer stack and the lossy electrodes are modelled using the method of lines. The microwave field distribution is determined, design curves are derived and the cross-sectional dimensions of the modulator are optimized. The loss of the fabricated device agrees very well with small signal measurements up to 40 GHz and HFSS simulations.

1 Introduction

High speed modulators are of great interest for 40 Gb/s transmission systems and beyond. Travelling wave modulators (Walker, 1991) are not limited in frequency by the RC time constant. A Mach-Zehnder modulator has been realized, e.g., on GaAs (Walker, 1995) and on InP (Mörl et al., 1999; Krähenbühl, 1998). However, little is published about the microwave design considerations that are to be taken into account in the design of high-speed travelling wave Mach-Zehnder modulators on InP. Highly accurate design data are necessary for these devices because of the long and costly fabrication process. Hence a rigorous model is needed that includes the main limiting factors: the velocity mismatch between the optical wave and the microwave as well as the microwave loss.

The waveguide structure of the modulator considered here (Fig. 2) is composed of several semiconductor layers with a step index profile and lossy metallic electrodes. Conventional analyses use a model with homogeneous dielectric layers and infinitely thin electrodes, which does not take the conductor losses into account. This yields an error in the microwave phase velocity and an incorrect electric field. In this paper, the model used fully accounts for the microwave and optical properties of the inhomogeneous layer stack. The loss in the modulating electrodes and in the semiconductor layers is considered by means of a complex dielectric constant.

The model structure is analyzed by the method of lines (MoL), which has been efficiently used for the simulation of various planar waveguides for microwave integrated circuits and integrated optics (Pregla and Pascher, 1989; Rogge and Pregla, 1993; Pregla and Pascher, 1995). The MoL takes advantage of the planar layer stack by discretizing the wave equation in the direction parallel to the interfaces of the layers, whereas an analytical solution is retained in the vertical direction. Thus highly accurate results are obtained at a comparatively small numerical effort. In this paper, we present MoL simulations to optimize the electric field across the reverse biased diode of the modulator. The results were confirmed by HFSS (High-Frequency Structure Simulator) and by measurements.

1.1 Modulator layout and cross-section

Since a reverse bias is used and almost no current is flowing in InP-based Mach-Zehnder switches, they can operate at sub-nanosecond speed. If lumped metal contacts are used, i.e. on top of the interferometer arms and on the bottom of the chip, the optical bandwidth of the modulator is limited to a couple of GHz by the capacitance. In a travelling wave design, the capacitance is distributed along the line and is consequently no longer a bandwidth limiting factor. In an ideal design, the modulating microwaves are travelling along the phase-shifter with a low attenuation at the same speed as that of the optical waves.

Figure 2 shows a cross-section of an interferometer arm. The RF-signal is fed to this modulator arm by a coplanar waveguide (CPW). At the beginning of the phase shifting sections, the CPW is transferred into a microstrip by a n⁺-buffer layer underneath an optical ridge waveguide. In this ridge the light is confined in a 500 nm thick InGaAsP layer (Q1.25) with a bandgap wavelength of 1.25 µm. The InP-cladding consists of an 200 nm thick intrinsic layer and a
p-doped layer. Due to the pin-structure of the optical waveguide, the microwave electric field needed for the electro-optic effect will be across the depleted region, which consists of the upper part of the film layer and the intrinsic layer.

2 Vectorial analysis by the method of lines

The analysis is based on the method of lines (MoL) as presented in Pregla and Pascher (1989). The MoL is a semi-analytic approach with analytic solution in one coordinate direction, namely perpendicular to the layers and a finite-difference discretization in the other direction. This approach is very well suited for multilayered waveguides as, e.g., for the travelling wave modulator under consideration. The cross-section of a modulator (as in Fig. 2) is partitioned into an “arbitrary” number of layers. These layers are inhomogeneous, also with permittivity steps ($\varepsilon_r = \varepsilon_r(x)$), dielectric loss ($\varepsilon_r$ complex) and metallic loss ($\varepsilon_r = -j\frac{k}{\omega \varepsilon_0}$).

The wave equations are established using two scalar potentials $\psi_e$ (electric) and $\psi_h$ (magnetic). We obtain a Helmholtz- and Sturm-Liouville differential equation for each layer

$$\varepsilon(x) \frac{\partial^2 \psi_e}{\partial x^2} + \varepsilon_r(x) \frac{\partial^2 \psi_e}{\partial x^2} + \left( \varepsilon_r(x) k_0^2 - k_z^2 \right) \psi_e = 0$$

(1)

$$\frac{\partial^2 \psi_h}{\partial x^2} + \frac{\partial^2 \psi_h}{\partial y^2} + \left( \varepsilon_r(x) k_0^2 - k_z^2 \right) \psi_h = 0$$

(2)

where we have assumed wave propagation in $z$ direction according to $\psi_{e,h} \sim \exp(-jk_z z)$.

The analysis steps of the method of lines for the electro-optic modulator are summarized in the flow chart (Fig. 3).

We apply a finite difference discretization in $x$ direction in order to convert to partial differential equations to coupled ordinary ones. In this way we are able to obtain an analytical solution in $y$ direction on discretization lines. Two sets of discretization lines are used, one for the electric potential $\psi_e$ and the other for the magnetic one $\psi_h$. The first derivative with respect to $x$ is expressed using finite differences and the following difference operator $D$ for the magnetic potential $\psi_h$

$$\frac{\partial \psi_h}{\partial x} \bigg|_{i(1/2)h} \approx \frac{\psi_{i+1} - \psi_i}{h}$$

or

$$h \frac{\partial \psi_h}{\partial x} \rightarrow \begin{bmatrix} 1 & -1 & 1 \\ -1 & 1 & -1 \\ \vdots & \ddots & \ddots \\ -1 & 1 & -1 \\ \psi_1 & \psi_2 & \vdots & \psi_{N-1} & \psi_N \end{bmatrix} = D \psi_h$$

(3)

The second derivative is given by

$$h^2 \frac{\partial^2 \psi_h}{\partial x^2} \rightarrow -D^T D \psi_h = -P_h \psi_h$$

with tridiagonal $P_h$ and analogous for the electric potential $\psi_e$. This yields the discretized wave equation (a system of coupled ordinary differential equations)

$$\frac{d^2}{dx^2} \psi_h - \left( k_z^2 I - \varepsilon_r + P_h \right) \psi_h = 0$$

(4)

with a tridiagonal matrix $Q_h$. In order to solve these equations, we perform a diagonalization, namely by transformation to principal axes:

$$T^{-1} Q T = \Gamma$$

(5)

$$T^{-1} \psi = \tilde{\psi}$$

This constitutes two separate eigenvalue problems for $\psi_e$ and $\psi_h$. We end up with the transformed Helmholtz equation

$$\frac{d^2}{dy^2} \tilde{\psi} - \Gamma^2 \tilde{\psi} = 0$$

(6)

which is decoupled and has an analytical solution in each individual layer

$$\tilde{\psi} = \exp(-\Gamma y) A + \exp(\Gamma y) B$$

(7)

In the following process the tangential fields are matched on each layer interface and we obtain a formulation of an indirect eigenvalue problem

$$Z(\varepsilon_{re}) \tilde{H}_{tan,M} = 0$$

(8)

$$\det(Z(\varepsilon_{re})) = 0$$

(9)
3 Simulation and measurement results

The modulator has been simulated by the MoL according to the cross-section in Fig. 2. First the field distribution is given. Then design curves with respect to various dimensions of the device are presented in order to optimize its performance. Finally, the microwave loss and index are compared with small signal measurements and HFSS (High-Frequency Structure Simulator) simulations.

3.1 Field distribution

The microwave electrical field distribution is presented for the optimized design (see next section), namely in the right half of the cross-section (Fig. 4). It can be seen clearly that the microwave field is concentrated in the depletion region. The wide signal electrode, however, produces a stray field in air, which allows some control of the microwave refractive index. Obviously, the mode encountered is nearly a microstrip mode. The reason lies in the comparatively high conductivity of the n-doped buffer layer, which acts as a kind of ground plane.
3.2 Design curves

The biggest electro-optic effect will be obtained if the electric field is highest in the region where the light is confined. To make use of the p-n diode structure of the ridge, doping of the InP-ridge is necessary. Unfortunately, doped semiconductors have a conductivity that is much lower than that of metals. Therefore, the amount of doping in the cladding influences the RF-attenuation due to varying resistivity.

Figure 5 (simulated using the package MOLCAR; Kremer and Pregla, 1997) shows the attenuation is decreasing as the ridge width, and thus the amount of doped material in between the signal line and the depletion-zone edge, is decreased. Figure 5 also shows the effect of the shape of the signal line on the RF-attenuation. A wider signal line width reduces the RF propagation loss, because a bigger part of the electric field is concentrated in the air instead of the semiconductor material. The attenuation is also reduced if the gold thickness is increased. Since the skin depth of Au is about 385 nm at 40 GHz, especially at thin Au thicknesses the attenuation increases dramatically. All plots were simulated at 40 GHz.

3.3 Comparison with measurements

The optimized design as described in the previous sections, has not been fabricated yet. Therefore, we checked measurements on already existing modulators with simulations by the Method of Lines. The left part of Fig. 6 shows the attenuation data of a structure with a ridge width of 4 µm and a signal line width of 12 µm. The measured values for the phase-shifting section have been extracted using the thru-reflect-line (TRL) method (Enge and Hoer, 1979). Depicted are the values measured through small signal (SS-)measurements, calculated by the MoL and calculated by HFSS.

HFSS simulations have been performed using the same structure as for the MOLCAR simulations. HFSS (Ansoft) is a 3-dimensional finite difference EM field solver. The structure is discretised in tetrahedra and the EM field components are calculated on the vertices and edges of these elements using appropriate boundary conditions. The mesh is refined adaptively at the locations where a large gradient exists. The output of a simulation is a.o. the impedance at the ports and the S-parameters. From these the complex propagation constant of the structure is calculated.

Comparison with measured values is very good. It can be noted that the loss curve does not follow a $\sqrt{f}$ law, since the losses are mainly determined by the absorption in the substrate and not by the skin depth of the electrodes.

The right part of Fig. 6 shows the real part of the microwave index of a structure with a signal line width of 12 µm. The high value of the index clearly shows that we are dealing with a slow wave structure which means that the velocity of the microwave is lower than the a wave in the
materials considered. This is caused by the doped semiconductor layers.

One of the causes for the offset between simulation and measurement of the effective index could be the lack of reliable data of the used polyimide at RF-frequencies. Also, since the calculated values of the MoL and HFSS agree very well, we believe another source of error is the uncertainty of the doping levels in the different layers, which has not been measured. A different doping profile would not only change the conductivities, but also the thickness of the depletion layer. Attenuation and effective index plots for a structure with a signal line width of $w_{\text{sig}} = 6 \mu \text{m}$ showed similar behaviour.

4 Conclusion

The method of lines (MoL) has been employed to model and design a fast travelling-wave electro-optic modulator. Field distributions and design curves have been presented and discussed in view of an optimized component with minimum microwave loss. The small-signal measurements of the fabricated device show very good agreement (better than 0.5 dB/mm) with the MoL modelling and with HFSS simulation results.

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